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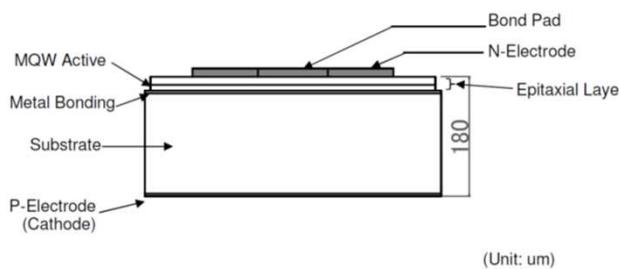
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**Data Sheet****LED Chip Infrared****EOLC-850-22-1**

Rev. 03, 2017

Radiation	Type	Electrodes
Infrared	InAlGaAs epitaxial layer, MQW	n (cathode) up

 (Unit: um)	typ. dimensions
	typ. die size: 510 x 510 μm typ. thickness: 180 μm typ. bond pad size: 120 μm anode metallization: gold-alloy cathode metallization: gold-alloy

Optical and Electrical Characteristics $T_{\text{amb}} = 25^\circ\text{C}$, unless otherwise specified

Parameter	Test cond.	Symbol	Min	Typ	Max	Unit
Forward voltage	$I_F=100 \text{ mA}$	V_F		1.48		V
Forward voltage	$I_F=150 \text{ mA}$	V_F		1.53		V
Reverse current	$V_R=5 \text{ V}$	I_R			10	μA
Radiant power*	$I_F=100 \text{ mA}$	Φ_e		38		mW
Radiant power*	$I_F=150 \text{ mA}$	Φ_e		50		mW
Peak wavelength	$I_F=20 \text{ mA}$	λ_p		850		nm
FWHM	$I_F=20 \text{ mA}$	$\Delta\lambda_{0.5}$		25		nm

*Measured on epoxy covered chip on TO-18 header

Packing

Dice on adhesive film with wire bond side up.

Art. No. 113 076



We reserve the right to make changes to improve technical design and may do so without further notice. Parameters can vary in different applications. All operating parameters must be validated for each customer application by the customer.